



**pico** **sun**  
AGILE ALD

**WELCOMES YOU TO  
ALD 2018!**

**The AVS 18<sup>th</sup> International Conference on Atomic Layer Deposition (ALD 2018) takes place in Songdo Convensia, Incheon, South Korea, from 29 July to 1 August 2018.**

As a platinum sponsor of the conference, Picosun wishes to see you all in ALD 2018!

Visit the Picosun booth # 32-33 to hear the latest news and see the new products from the headquarters of AGILE ALD™. Remember also to fill our PicoSurvey™ questionnaire and participate in a lottery of an Apple Watch!

If you wish to pre-book a meeting, please contact [sales@picosun.com](mailto:sales@picosun.com) directly – we're happy to help you in all your ALD requirements.

On Monday evening July 30 at 7 pm it's again time for our traditional ALD hospitality party at the Sheraton Grand Incheon Hotel.

The party is hosted together with Applied Materials, NSI, Air Liquide, LAM Research, and EMD Performance Materials. Invitations to the party are delivered at the Picosun booth.

Be quick, as the invitations are personal and their amount is limited! Let's relax after a hectic conference day with great food, drinks, whiskey and *soju* tasting, live music, entertainment and networking in informal atmosphere, right next door to the conference center!

This year, Picosun has two oral and one poster presentations. Bookmark the times:

- **Mon July 30, 5:45 – 7:00 pm:** Dr. Tero Pilvi: Screening of ALD barrier materials towards use in LED lighting (poster).
- **Tue July 31, 8:15 – 8:30 am:** Mr. Juhana Kostamo: Low-temperature thermal ALD of SiO<sub>2</sub> – increasing the possibilities (oral).
- **Tue July 31, 2:00 – 2:15 pm:** Dr. Tero Pilvi: Stresses in ALD films: Aiming for zero stress thin films (oral).

Looking forward to seeing you in ALD 2018!

**Visit us at  
BOOTH 32-33**



[www.picosun.com](http://www.picosun.com)